## Supplementary Information

## Selective Catalytic NO<sub>x</sub> Reduction by H<sub>2</sub> in Excess O<sub>2</sub> over Pt/Zirconium Phosphate Nanosheet.

Keisuke Awaya,<sup>\*a</sup> Yuka Sato,<sup>b</sup> Aoi Miyazaki,<sup>b</sup> Mana Furukubo,<sup>b</sup> Koshi Nishiyama,<sup>b</sup> Masayuki Tsushida,<sup>c</sup> Shintaro Ida,<sup>d</sup> Junya Ohyama,<sup>a,d</sup> Masato Machida<sup>\*a,d</sup>

a) Faculty of Advanced Science and Technology, Kumamoto University; 2-39-1, Kurokami, Chuo-ku, Kumamoto, 860-8555, Japan.

b) Graduate School of Science and Technology, Kumamoto University; 2-39-1, Kurokami, Chuo-ku, Kumamoto, 860-8555, Japan.

c) Technical Division, Kumamoto University; 2-39-1, Kurokami, Chuo-ku, Kumamoto, 860-8555, Japan.

d) Institute of Industrial Nanomaterials (IINa), Kumamoto University; 2-39-1, Kurokami, Chuoku, Kumamoto, 860-8555, Japan.



**Figure S1.** In-plane XRD patterns ( $2\theta\chi/\phi$  scan) of the ZrP nanosheet spin-coating film deposited on a Si wafer before and after annealing at 100-800  $^{\circ}$ C for 1 h.



**Figure S2.** Powder XRD patterns (20/0 scan) of the  $\alpha$ -ZrP ( $\alpha$ -Zr(HPO<sub>4</sub>)<sub>2</sub>·H<sub>2</sub>O) before and after annealing at 200-500 °C for 1 h, ICSD #1281 ( $\alpha$ -Zr(HPO<sub>4</sub>)<sub>2</sub>·H<sub>2</sub>O), and ICSD #280395 (ZrP<sub>2</sub>O<sub>7</sub>).



**Figure S3.** Out-of-plane XRD patterns (20/ $\theta$  scan) of the ZrP nanosheet spin-coating film deposited on a Si wafer before and after annealing at 100-800  $^{\circ}$ C for 1 h.



**Figure S4.** Thickness and lateral size distributions of the ZrP nanosheet deposited on a Si wafer (analysis of AFM images).



**Figure S5.** FE-SEM images of the (a)  $\alpha$ -ZrP ( $\alpha$ -Zr(HPO<sub>4</sub>)<sub>2</sub>·H<sub>2</sub>O) and (b) restacked ZrP nanosheet.



Figure S6. FE-SEM images of (a) 0.08, (b) 0.14, (c) 0.22, and (d) 0.49 wt% Pt (ads.)/ZrP nanosheet.



**Figure S7.** FE-SEM images of the (a) 0.5 wt% Pt (ads.)/ $\alpha$ -Zr(HPO<sub>4</sub>)<sub>2</sub>·H<sub>2</sub>O and (b) 0.4 wt% Pt (ads.)/ZrP<sub>2</sub>O<sub>7</sub>.



Figure S8. FE-SEM image of the freeze-dried ZrP nanosheet.



**Figure S9.** Powder XRD patterns ( $2\theta/\theta$  scan) of the (a) hexylamine (HA)- and the (b) decylamine (DA)-restacked ZrP nanosheet.



**Figure S10.** A HAADF-STEM image of the Pt (particle size ~ 14 nm) particle on ZrP nanosheet (0.49 wt% Pt (ads.)/ZrP nanosheet).



**Figure S11.** HAADF-STEM images of the (a-b) 0.14 wt% Pt (ads.)/ZrP nanosheet and (c) 0.16 wt% Pt (imp.)/ZrP nanosheet.



**Figure S12.** HAADF-STEM images showing Pt clusters and atomically-dispersed Pt on (a) 0.49 wt% Pt (ads.)/ZrP nanosheet and (b) 0.14 wt% Pt (ads.)/ZrP nanosheet.



**Figure S13.** (a-d) HAADF-STEM images of 0.4 wt% Pt (ads.)/ZrP<sub>2</sub>O<sub>7</sub>. The images (b), (c), and (d) are zoomed images of the area marked by X, Y, and Z in (a).



**Figure S14.** (a-d) HAADF-STEM images of 0.5 wt% Pt (ads.)/ $\alpha$ -Zr(HPO<sub>4</sub>)<sub>2</sub>·H<sub>2</sub>O. The images (b), (c), and (d) are zoomed images of the area marked by X, Y, and Z in (a).



**Figure S15.** (a) Maximal NO conversion for H<sub>2</sub>-SCR over 0.08 (200 °C), 0.14 (175 °C), 0.22 (175 °C), and 0.49 wt% (150 °C) Pt (ads.)/ZrP nanosheet. (b) N<sub>2</sub> selectivity over 0.08-0.49 wt% Pt (ads.)/ZrP nanosheet at the same temperatures for (a).



**Figure S16.** Temperature dependence of NO conversion and product yields over 0.16 wt% Pt (imp.)/ZrP nanosheet. NO (200 ppm), H2 (5,000 ppm), O2 (10%), and He balance.



**Figure S17.** Powder XRD patterns ( $2\theta/\theta$  scan) of the 0.51 wt% Pt (ads.)/ZrP nanosheet before and after examining 3 cycles of H<sub>2</sub>-SCR performance test.



**Figure S18.** Continuous H<sub>2</sub>-SCR performance test over 0.51 wt% Pt (ads.)/ZrP nanosheet at 150 °C in NO (200 ppm), H<sub>2</sub> (5,000 ppm), O<sub>2</sub> (10%), and He balance ( $W_{catalyst}$  = 44.9 mg).



**Figure S19.** Temperature dependence of NO conversion and product yields over 0.4 wt% Pt/SiO<sub>2</sub>. NO (200 ppm), H2 (5,000 ppm), O2 (10%), and He balance.



**Figure S20.** Pt 4f XPS spectra of 0.5 wt% Pt (ads.)/ $\alpha$ -Zr(HPO<sub>4</sub>)<sub>2</sub>·H<sub>2</sub>O and 0.4 wt% Pt (ads.)/ZrP<sub>2</sub>O<sub>7</sub>. The intensity was normalized using the maximal intensity of Zr3d spectra.

Samples	S <sub>BET</sub> / m²/g
α-ZrP (as prepared)	13.2
Restacked ZrP nanosheet (0.1 M HCI)	26.1
Freeze-dried ZrP nanosheet	12.4
HA-intercalated ZrP nanosheet (400 $^\circ\!\mathrm{C}$ /1 h/air)	40.0
DA-intercalated ZrP nanosheet (400 $^\circ\!\mathrm{C}$ /1 h/air)	25.3

**Table S1.** BET specific surface area ( $S_{BET}$ ) of the  $\alpha$ -ZrP ( $\alpha$ -Zr(HPO<sub>4</sub>)<sub>2</sub> · H<sub>2</sub>O) and its derivatives.

**Table S2.** Comparison of the maximal NO<sub>x</sub> conversion (conv.), N<sub>2</sub> selectivity, N<sub>2</sub>O yield (100 °C), and NO<sub>2</sub> yield (300 °C) over the Pt-based H<sub>2</sub>-SCR catalyst reported in previous literatures.

Samala	Feed gas composition;	Maximal	N <sub>2</sub>	N <sub>2</sub> O yield	NO <sub>2</sub> yield	Def	
Sample	Space velocity	NO <sub>x</sub> conv.	selectivity	at 100 °C	± 100 ℃ at 300 ℃		
110/ D1/T: NACNA 44	NO/H <sub>2</sub> /O <sub>2</sub> = 0.1%/0.5%/6.7%, He balance;	88%	79%	1	1041		
1Wt% Pt/11-MCM-41	80,000 h <sup>-1</sup>	140 °C	140 °C	n/a	n/a	[S1]	
0.0440/ DUALMON 44	NO/H <sub>2</sub> /O <sub>2</sub> = 0.1%/0.5%/6.7%, He balance;	80%	85%				
0.94wt% Pt/AI-MCM-41	80,000 h <sup>-1</sup>	120 °C	120 °C	n/a	n/a	[52]	
4+0/ D1/70M 05	NO/H <sub>2</sub> /O <sub>2</sub> = 0.1%/0.5%/6.7%, He balance;	81%	69%	- 1-		1001	
TWt% Pt/2SIM-35	80,000 h <sup>-1</sup>	120 °C	120 °C	n/a	n/a	[83]	
	NO/NO <sub>2</sub> /H <sub>2</sub> /O <sub>2</sub> = 0.091%/0.009%/0.5%/10%,	87%	69%		E 40/	10.41	
0.5wt% Pt/H-FER	He balance; 36,000 h <sup>-1</sup>	110 °C	110 °C	n/a	54%	[S4]	
	NO/H <sub>2</sub> /O <sub>2</sub> = 0.1%/0.5%/10%, He balance; 81% 75%	n la	1051				
0.5Wt% Pt/Ht	32,000 h <sup>-1</sup>	130 °C	130 °C	n/a	n/a	[85]	
1t0/ Dt/CCZ 12	NO/H <sub>2</sub> /H <sub>2</sub> O/O <sub>2</sub> = 0.1%/0.5%/5%/10%,	98%	23%	000/	600/	10.61	
IWI% PI/552-13	He balance; 20,000 h <sup>-1</sup>	100 °C	100 °C	00%	00%	[30]	
1 5wt9/ Dt/70M 5	NO/H <sub>2</sub> /H <sub>2</sub> O/O <sub>2</sub> = 0.05%/0.5%/5%,	99%	79%	nla	220/	1071	
1.5WL% PVZ 5WI-5	He balance; 120,000 ml/h • g <sub>cat</sub>	75 °C	75 °C	n/a	22%	[97]	
21.49/ Dt/Ma	NO/H <sub>2</sub> /O <sub>2</sub> = 0.048%/0.8%/5%, He balance;	63%	30%	240/		10.01	
2wt% Pt/MnO <sub>x</sub>	78,000 h <sup>-1</sup>	100 °C	100 °C	34 %	n/a	[58]	
1wt% Pt/Ti <sub>0.5</sub> Zr <sub>0.5</sub>	NO/H <sub>2</sub> /O <sub>2</sub> = 0.03%/0.24%/5%, N <sub>2</sub> balance;	97%	60%	2/2	13%	3% 50 °C) [S9]	
(TiO <sub>2</sub> +ZrO <sub>2</sub> +ZrTiO <sub>4</sub> )	36,000 h <sup>-1</sup>	130 °C	130 °C	n/a	(250 °C)		
0.49wt% Pt (ads.)/ZrP	NO/H <sub>2</sub> /O <sub>2</sub> = 0.02%/0.5%/10%, He balance;	89%	83%	160/	00/	This	
nanosheet	120,000 ml/h•g <sub>cat</sub> ,~50,000 h <sup>-1</sup>	150 °C	150 °C	10%	9%	work	

Pt loading amount of	Mathad	D+0 / 0/		Pt <sup>iv</sup> -O / %	
Pt/ZrP nanosheet / wt%	Method	Ρι°/ %	Pl"-0 / %		
0.08	Ads.	33.4	47.8	18.8	
0.14	Ads.	31.4	48.9	19.7	
0.22	Ads.	29.3	56.5	14.2	
0.49	Ads.	29.2	58.3	12.5	
0.16	Imp.	30.4	56.2	13.4	

**Table S3.** Percentages of Pt species of 0.08-0.49 wt% Pt (ads.)/ZrP nanosheet and 0.16 wt% Pt (imp.)/ZrP nanosheet (XPS analysis).

**Table S4.** Percentages of Pt species of 0.4 wt% Pt (ads.)/ $ZrP_2O_7$  and 0.5 wt% Pt (ads.)/ $\alpha$ -Zr(HPO<sub>4</sub>)<sub>2</sub>·H<sub>2</sub>O (XPS analysis).

Samples	Method	Pt <sup>0</sup> / %	Pt <sup>II</sup> -O / %	Pt <sup>IV</sup> -O / %
0.4 wt% Pt/ZrP <sub>2</sub> O <sub>7</sub>	Ads.	54.1	32.7	13.2
0.5 wt% Pt/α-Zr(HPO₄)₂·H₂O	Ads.	34.4	49.0	16.6

## References

[S1] L. Li, P. Wu, Q. Yu, G. Wu, N. Guan, Appl. Catal. B, 2010, 94, 254-262.

[S2] P. Wu, L. Li, Q. Yu, G. Wu, N. Guan, Catal. Today, 2010, 158, 228-234.

- [S3] Q. Yu, M. Richter, F. Kong, L. Li, G. Wu, N. Guan, Catal. Today, 2010, 158, 452-458.
- [S4] S. Yang, X. Wang, W. Chu, Z. Song, S. Zhao, Appl. Catal. B, 2011, 107, 380-385.
- [S5] X. Zhang, X. Wang, X. Zhao, Y. Xu, H. Gao, F. Zhang, Chem. Eng. J., 2014, 252, 288-297.

[S6] J. Shao, P. H. Ho, D. Creaser, L. Olsson, Appl. Catal. O, 2024, 188, 206947.

[S7] D. C. Park, S. Moon, J. H. Song, H. Kim, E. Lee, Y. H. Lim, D. H. Kim, *Catal. Today*, 2024, *425*, 114318.

[S8] S. M. Park, M. -Y. Kim, E. S. Kim, H. -S. Han, G. Seo, Appl. Catal. A, 2011, 395, 120-128.

[S9] Y. Li, D. He, H. Zhao, M. Pei, Y. Fan, H. Xu, J. Wang, Y. Chen, *Chem. Eng. J.*, 2024, 490, 151714.